



L4 ANSWER 2 OF 2 USPATFULL on STN  
AN 2001:117126 USPATFULL  
TI Method for preparing polyether polymers of predetermined molecular  
IN Fyvie, Thomas Joseph, Schenectady, NY, United States  
Phelps, Peter David, Schenectady, NY, United States  
Howson, Paul Edward, Latham, NY, United States  
Rohr, Donald Frank, Rexford, NY, United States  
Kailasam, Ganesh, Clifton Park, NY, United States  
Shanklin, Elliott West, Altamont, NY, United States  
PA General Electric Company, Schenectady, NY, United States (U.S.  
corporation)  
PI US 6265521 B1 20010724  
AI US 2000-632675 20000807 (9)  
DT Utility  
FS GRANTED  
LN.CNT 650  
INCL INCLM: 528/170.000  
INCLS: 528/125.000; 528/126.000; 528/128.000; 528/171.000; 528/172.000;  
528/173.000; 528/174.000; 528/175.000; 528/179.000; 528/182.000;  
528/183.000; 528/185.000; 528/188.000; 528/214.000; 528/215.000;  
528/219.000; 528/220.000; 528/229.000; 528/351.000; 528/352.000;  
528/353.000  
NCL NCLM: 528/170.000  
NCLS: 528/125.000; 528/126.000; 528/128.000; 528/171.000; 528/172.000;  
528/173.000; 528/174.000; 528/175.000; 528/179.000; 528/182.000;  
528/183.000; 528/185.000; 528/188.000; 528/214.000; 528/215.000;  
528/219.000; 528/220.000; 528/229.000; 528/351.000; 528/352.000;  
528/353.000  
IC [7]  
ICM: C08G073-10  
ICS: C08G069-28; C08G008-02  
EXF 528/170; 528/125; 528/126; 528/128; 528/171; 528/172; 528/173; 528/174;  
528/175; 528/179; 528/182; 528/185; 528/188; 528/183; 528/214; 528/215;  
528/219; 528/220; 528/229; 528/351; 528/352; 528/353  
CAS INDEXING IS AVAILABLE FOR THIS PATENT.

=> s bis N-chlorophthalimid# and alkali metal salt#  
5 FILES SEARCHED...  
L5 2 BIS N-CHLOROPHTHALIMID# AND ALKALI METAL SALT#  
=> d 15 1-2  
  
L5 ANSWER 1 OF 2 PCTFULL COPYRIGHT 2004 Univentio on STN  
AN 2001021686 PCTFULL ED 20020820  
TIEN METHOD FOR PURIFICATION OF AROMATIC POLYETHERS  
TIFR PROCEDE DE PURIFICATION DE POLYETHERS AROMATIQUES  
IN JOHNSON, Norman, Enoch;  
AYALA, Paul, Eduardo;  
FYVIE, Thomas, Joseph;  
FRESHOUR, Amy, Renne;  
WOODRUFF, David, Winfield;  
PHELPS, Peter, David;  
KAILASAM, Ganesh;  
HOWSON, Paul, Edward;  
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PA GENERAL ELECTRIC COMPANY  
DT Patent  
PI WO 2001021686 A1 20010329  
DS W: JP SG AT BE CH CY DE DK ES FI FR GB GR IE IT LU MC NL PT  
SE  
AI WO 2000-US25529 A 20000918  
PRAI US 1999-60/154,764 19990920  
US 2000-09/634,161 20000809  
ICM C08G073-10  
ICS C08G073-12; C08G065-40; C08G065-48

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                528/173.000; 528/174.000; 528/175.000; 528/179.000; 528/182.000;  
                528/183.000; 528/185.000; 528/188.000; 528/214.000; 528/215.000;  
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    528/175; 528/179; 528/182; 528/185; 528/188; 528/183; 528/214; 528/215;  
    528/219; 528/220; 528/229; 528/351; 528/352; 528/353  
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